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Electrochemical investigation and modeling of $\text{LaNi}_{4.77}\text{Al}_{0.23}$ thin-films sputtered on glass wafers

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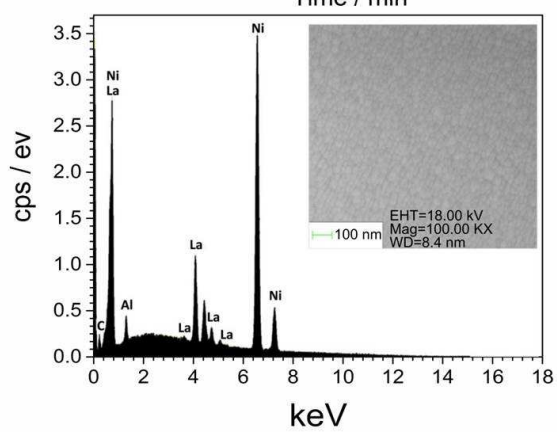
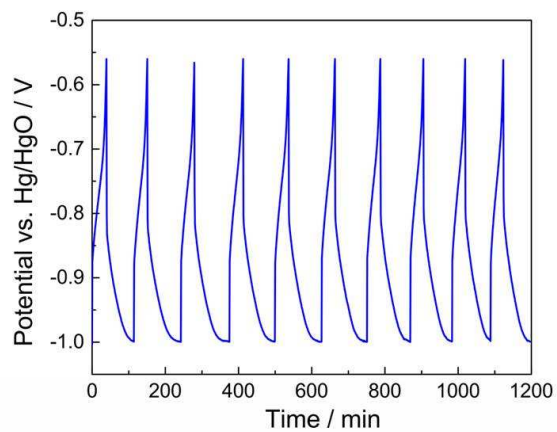
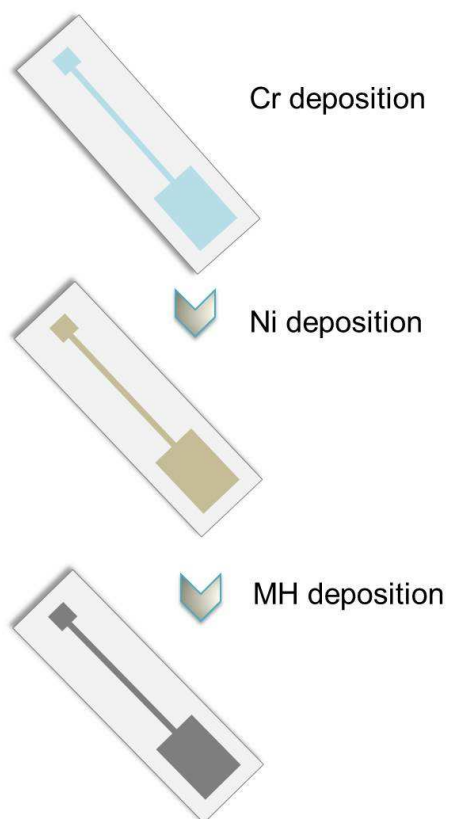
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